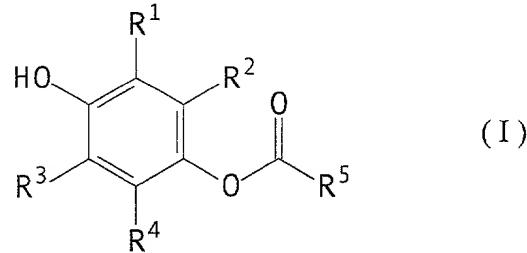


ABSTRACT OF THE DISCLOSURE

The object of the present invention is to provide an electrophotographic photoconductor that has sufficient resistance against ozone and exhibits improved stability in electrical characteristics. Another object of the invention is to provide 5 a method for manufacturing such a photoconductor.

An electrophotographic photoconductor of the present invention has a conductive substrate and a photosensitive layer on the substrate, in which the photosensitive layer contains a compound represented by the formula (I),



10 wherein each of R¹ to R⁴ are independently selected from the group consisting of a hydrogen atom, a halogen atom, an alkyl group of 1 to 4 carbon atoms, an alkoxy group, an alkyl halide group, an alkoxy halide group, or an optionally substituted aryl group, and R⁵ represents an optionally substituted alkyl group or an optionally substituted aryl group. The resulting electrophotographic 15 photoconductor has sufficient resistance against ozone and exhibits excellent stability in electrical characteristics.